
Stability of Metal-Organic Frameworks in presence of water: New insights from ^{17}O solid-state NMR

Florian Venel^{*1}, Frédérique Pourpoint¹, Olivier Lafon^{2,1}, Christophe Volkringer^{2,1}, and Danielle Laurencin³

¹Unité de Catalyse et Chimie du Solide - UMR 8181 (UCCS) – Univ. Lille, CNRS, Centrale Lille, ENSCL, Univ. Artois, UMR 8181 - UCCS - Unité de Catalyse et Chimie du Solide, F-59000 Lille, France – F-59000, Lille, France

²Institut Universitaire de France (IUF) – Institut universitaire de France – 1 rue Descartes, F-75231, Paris, France

³Institut Charles Gerhardt Montpellier - UMR 5253 (ICGM) – Ingénierie Moléculaire et Nano Objets (IMNO), Institut Charles Gerhardt (ICGM)-UMR5253, Univ. Montpellier, CNRS, ENSCM, Montpellier, France – Montpellier 34095, France

Résumé

Metal-Organic Frameworks (MOFs) are promising porous crystalline hybrid materials for various applications (gas separation or storage, catalysis, medicine, etc). Nevertheless, a major limitation of these materials remains their weak stability at high temperature or in the presence of water[1]. The stability of these MOFs in the presence of water remains a property difficult to predict and highly depends on the atomic-level structure of these materials. In the present work, we have used 1D and 2D ^{17}O solid-state NMR experiments to probe atomic-level interactions and exchanges of O atoms between water and MOFs. This original approach has been applied for UiO-66(Zr), a zirconium-based MOF promising for industrial applications because of its good stability[2]. These studies involved the preparation of different selectively ^{17}O -labeled UiO-66(Zr) MOFs using either ^{17}O -enriched water as the ^{17}O source[3] or ^{17}O -labeled ligands prepared by mechanochemistry[4].

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*Intervenant